

Application No. 09/936,041

In view of the foregoing amendments and remarks, Applicants submit that this application is in condition for allowance. Favorable reconsideration and prompt allowance of claims 1 - 24 are earnestly solicited.

Should the Examiner believe that anything further would be desirable in order to place this application in better condition for allowance, the Examiner is invited to contact Applicants' undersigned representative at the telephone number listed below.

Respectfully submitted,



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Date: September 3, 2002

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Docket No. 110553

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## APPENDIX

## Changes to Claims:

The following is a marked-up version of the amended claims:

14. (Amended) A method of manufacturing a display device comprising a thin-film transistor that is manufactured by:

forming a channel region facing a gate electrode through a gate insulating film;

forming source and drain regions connected to the channel region in a semiconductor film that is formed on a surface of an insulating substrate; and

forming a recombination center that captures carriers in the channel region by introducing an impurity into said channel region so that a distance between the recombination center and the drain region is shorter than a distance between the recombination center and the source region.